

# APPLICATION DATA SHEET

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Attorney Docket Number: ATMI-506

Publication Filing Type:

new-utility

Application Type:

utility

Title of Invention:

SYSTEM FOR IN-SITU GENERATION OF FLUORINE RADICALS  
AND/OR FLUORINE-CONTAINING INTERHALOGEN (XFn)  
COMPOUNDS FOR USE IN CLEANING SEMICONDUCTOR  
PROCESSING CHAMBERS

Customer Number Correspondence Address:

25559



## INVENTOR(s):

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